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# Electrophilic aromatic substitution of electron-rich arenes with *N*-fluorobenzenesulfonimide (NFSI) as an electrophile†

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An efficient amidation of electron-rich arenes using NFSI as a nitrogen source has been successfully disclosed. This amidation process can be easily conducted at elevated temperatures, without the need for catalysts or additives. A wide range of arenes substituted with hydroxy, alkoxy, or carbonyl groups were found to be compatible, yielding the desired amination products. Computational study shows that the amidation proceeds *via* an electrophilic aromatic substitution pathway, comprising a three-step process that includes substitution, addition, and elimination, which differs slightly from the classical mechanism.

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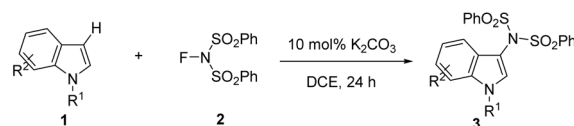
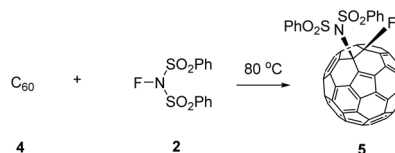
## Introduction

*N*-Fluorobenzenesulfonimide (NFSI)<sup>1–4</sup> is a readily available, stable, and highly soluble crystalline powder that is widely utilized as a fluorinating reagent<sup>5–14</sup> or oxidant in organic reactions.<sup>15–29</sup> Additionally, NFSI has proven to be an efficient source of nitrogen for the C–H bond amidation of aromatic, heteroaromatic, benzyl, allyl, and aldehyde groups.<sup>30–36</sup> In the amidation reactions, NFSI acts as a source of nitrogen radicals<sup>37</sup> or as a nucleophilic nitrogen in various metal-catalyzed transformations of aromatic and aliphatic compounds.<sup>38–67</sup> In this context, we describe a different type of amidation reaction in which NFSI serves as a source of electrophilic nitrogen, while the arene functions as a nucleophile.

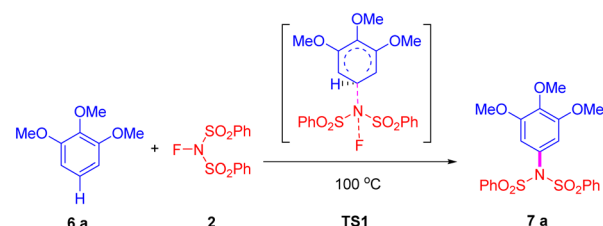
Several research groups have reported the regioselective amidation reactions of indoles, pyrroles, quinolones, and imidazoheterocycles, which were mediated solely by a base or the hypervalent iodine reagents under mild conditions without using any metallic catalyst or oxidant.<sup>68–71</sup> These groups hypothesized that the amidation reaction likely proceeds *via* a free radical mechanism (Scheme 1a).<sup>70</sup> Additionally, it has been documented that the fluorinating reagent NFSI can be added to C<sub>60</sub>, yielding adduct 5 with over 90% efficiency on a large scale, again without the necessity for a metal catalyst or base. A concerted (2 + 2) cycloaddition mechanism has been proposed for the formation of this adduct (Scheme 1b).<sup>72</sup>

Following the established literature procedures for metal-free amidation of heterocycles, we initially treated electron-rich arenes with NFSI. We were pleased to find that the mixture of 1,2,3-trimethoxybenzene (TMB) and NFSI could efficiently yield product 7a under elevated temperature conditions, without the need for any catalyst or additive (Scheme 1c). Furthermore, through density functional theory (DFT) calculations, we proposed a three-step mechanism characterized by the

a) Indoles reacted with NFSI


 b) C<sub>60</sub> reacted with NFSI


c) This work



Scheme 1 Reactions of arenes with NFSI without the need for catalysts.

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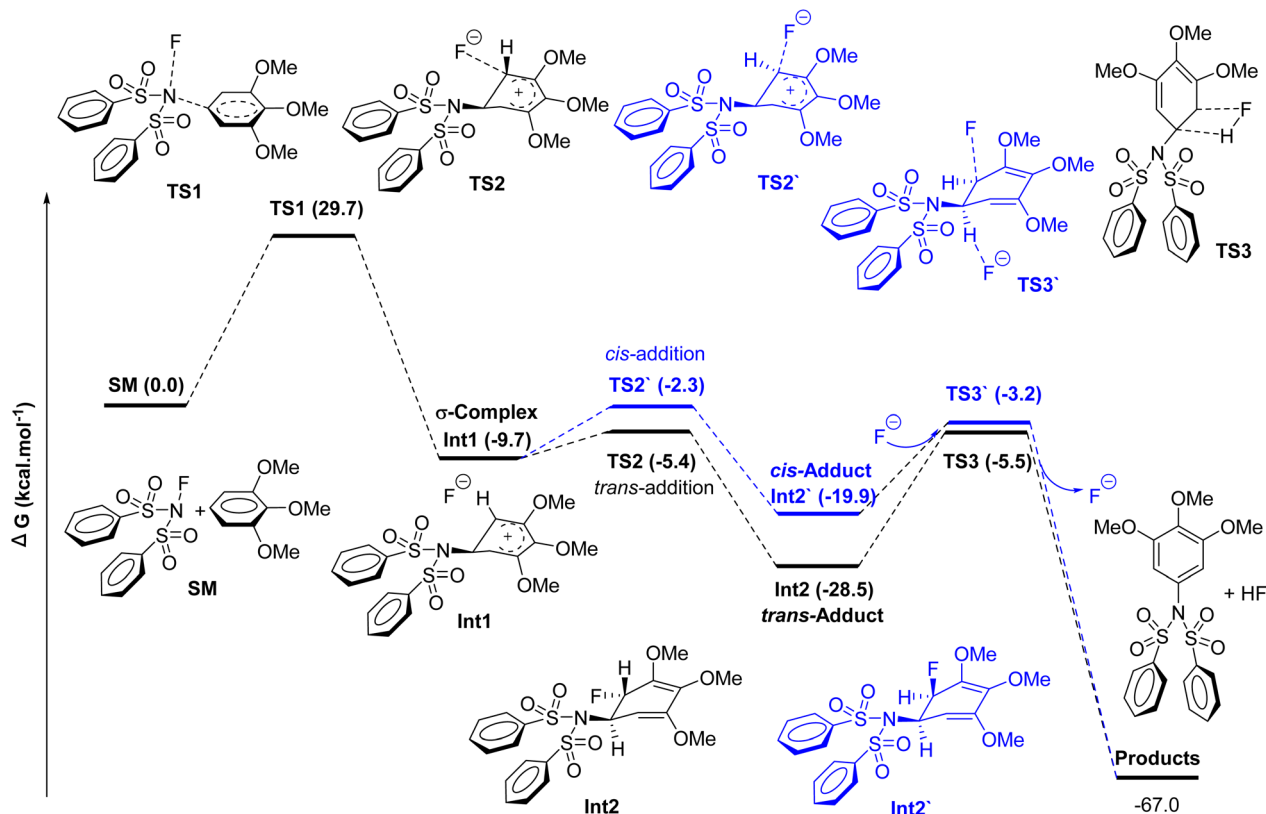


Fig. 1 Free energy profile for the amidation reaction at the wb97xd/6-311<sup>++</sup> level of theory.

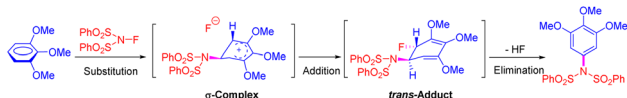
of amidated product (**7n**) as the major product. Conversely, 1,3,5-trimethoxybenzene (**7o**) and 2-methoxy naphthalene (**7p**) predominantly produced fluorinated compounds, with no amidation products detected.

Electrophilic aromatic substitution is a hallmark reaction in synthetic organic chemistry, typically understood as a two-step mechanism involving the formation of a  $\sigma$ -complex followed by the elimination of a small molecule.<sup>83</sup> Through a combination of computational and experimental investigations, we propose an alternative three-step mechanism characterized by substitution, addition, and elimination (Scheme 3).

Geometry optimizations and frequency calculations of all presented structures were performed at the wb97XD/6-311G\*\* level of theory,<sup>84</sup> and the complete mechanism is illustrated in Fig. 1. TMB initially attacks the nitrogen atom of NFSI, resulting in the  $\sigma$ -complex (**Int1**) via **TS1**. This step presents an energy barrier of 29.7 kcal mol<sup>-1</sup>, which can be regarded as the rate-determining step. Notably, the existence of **TS1** was further corroborated by Intrinsic Reaction Coordinate (IRC) calculations, confirming that the first-order saddle points identified represent genuine transition states connecting the starting materials and the  $\sigma$ -complex.

In light of the addition product of NFSI with C60, we propose that the resulting  $\sigma$ -complex does not undergo an elimination reaction directly but rather proceeds through an addition reaction.<sup>72,85</sup> Furthermore, extensive calculations indicate that this process occurs as a competition between *cis*- and *trans*-addition pathways. The fluorine anion of the  $\sigma$ -complex preferentially adds from the side opposite the nitrogen atom, resulting in the formation of the *trans*-adduct (**Int2**). This pathway requires overcoming a modest energy barrier of 4.3 kcal mol<sup>-1</sup>. Conversely, the fluorine anion may also engage in a *cis*-addition reaction, yielding the *cis*-adduct. However, the energy barrier for the *cis*-addition (**Int2'**) is 7.4 kcal mol<sup>-1</sup> higher than that for the *trans*-addition. Thus, based on these findings, we can conclude that the reaction proceeds through the kinetically favored *trans*-adduction pathway that leads to the corresponding *trans*-adduct.

The loss of aromaticity in both adducts leads to their immediate elimination. In the case of the *trans*-adduct, fluorine departs in conjunction with the adjacent hydrogen, resulting in the formation of the desired product, **7a**, which requires an energy input of 23.0 kcal mol<sup>-1</sup>. Similarly, the *cis*-adduct undergoes elimination facilitated by another fluorine anion, yielding the same product.



Scheme 3 Proposed mechanism for the amidation of TMB.

## Conclusions

In summary, we have developed a practical transition metal-free, regioselective amidation of electron-rich arenes using



NFSI as the commercially available amino source. This procedure can be conducted in both solvents and neat conditions, and it does not require any external oxidants or additives. The amidation process is compatible with a wide range of functional groups, including hydroxy, alkoxy, and carbonyl groups. DFT calculations support a three-step electrophilic aromatic substitution mechanism for this amidation reaction, wherein the  $\sigma$ -complex is formed first, followed by the production of two adduct isomers, and ultimately yielding the desired product through an elimination reaction. The formation of the  $\sigma$ -complex has been identified as the rate-determining step.

## Data availability

The authors confirm that the data supporting this article have been included as part of the ESI.†

## Conflicts of interest

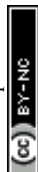
There are no conflicts to declare.

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## Notes and references

- W. C. Weilin Wang, J. Luo and P. Xie, *Chin. J. Org. Chem.*, 2021, **41**, 543–552.
- Q. Gu and E. Vessally, *RSC Adv.*, 2020, **10**, 16756–16768.
- S. Sushmita, T. Aggarwal, S. Kumar and A. K. Verma, *Org. Biomol. Chem.*, 2020, **18**, 7056–7073.
- Y. Li and Q. Zhang, *Synthesis*, 2015, **47**, 159–174.
- Z.-M. Yan, L. Qi, T.-Y. Cao, J.-L. Liu, H.-J. Du, Y.-C. Dong, W. Li and L.-J. Wang, *Org. Lett.*, 2023, **25**, 3910–3915.
- Y. Ito, A. Adachi, K. Aikawa, K. Nozaki and T. Okazoe, *Chem. Commun.*, 2023, **59**, 9195–9198.
- O. M. Shavrina, P. P. Onys'ko and Y. V. Rassukana, *J. Fluorine Chem.*, 2022, **261–262**, 110027.
- L. Jin, X. Zeng, S. Li, G. Qiu and P. Liu, *Eur. J. Org. Chem.*, 2022, **2022**, e202200399.
- J. G. Hernández, K. J. Ardila-Fierro, D. Barišić and H. Geneste, *Beilstein J. Org. Chem.*, 2022, **18**, 182–189.
- S. Ogasawara, K. Nakano and H. Tamiaki, *Tetrahedron*, 2020, **76**, 131722.
- C. Shi, Q. Miao, L. Ma, T. Lu, D. Yang, J. Chen and Z. Li, *ChemistrySelect*, 2019, **4**, 6043–6047.
- F. Sakurai, T. Yukawa and T. Taniguchi, *Org. Lett.*, 2019, **21**, 7254–7257.
- V. Levchenko, Y. V. Dmytriv, A. V. Tymtsunik, K. Liubchak, A. Rudnichenko, A. V. Melnyk, S. Y. Veselovych, Y. V. Borodulin, O. M. Otsalyuk, A. A. Tolmachev and P. K. Mykhailiuk, *J. Org. Chem.*, 2018, **83**, 3265–3274.
- M. Meanwell, M. B. Nodwell, R. E. Martin and R. Britton, *Angew. Chem., Int. Ed.*, 2016, **55**, 13244–13248.
- F. Bao, *Asian J. Org. Chem.*, 2023, **12**, e202300407.
- X. Zhang, Y. Feng, Y. Tuo and Q.-Z. Zheng, *Org. Biomol. Chem.*, 2022, **20**, 768–772.
- Y.-Q. Jiang, Y.-H. Wang, C.-F. Zhou, Y.-Q. Zhang, Y. Ling, Y. Zhao and G.-Q. Liu, *J. Org. Chem.*, 2022, **87**, 14609–14622.
- B. Božić, J. Ladarević, M. Petković, D. Mijin and S. Stavber, *Catalysts*, 2022, **12**, 1413.
- X. Xu, L. Yan, S. Wang, P. Wang, A. X. Yang, X. Li, H. Lu and Z.-Y. Cao, *Org. Biomol. Chem.*, 2021, **19**, 8691–8695.
- L.-Q. Liu, J.-L. Li, Y.-C. Wang and H.-S. Wang, *Results Chem.*, 2021, **3**, 100220.
- S. Liu, Y. Huang, X.-H. Xu and F.-L. Qing, *J. Fluorine Chem.*, 2020, **240**, 109653.
- G. Liang, Y. Ji, H. Liu, Y. Pang, B. Zhou, M. Cheng, Y. Liu, B. Lin and Y. Liu, *Adv. Synth. Catal.*, 2020, **362**, 192–205.
- Q. Lin, Y. Liu, Z. Xiao, L. Zheng, X. Zhou, Y. Guo, Q.-Y. Chen, C. Zheng and C. Liu, *Org. Chem. Front.*, 2019, **6**, 447–450.
- J. H. Jing Lia, G. Meib, W. Xiaohuaa, W. Qiantaoa and W. Yonga, *Chin. J. Org. Chem.*, 2018, **38**, 692–697.
- Y. Liu, H. Wu, Y. Guo, J.-C. Xiao, Q.-Y. Chen and C. Liu, *Angew. Chem., Int. Ed.*, 2017, **56**, 15432–15435.
- M. Song, Q. Hu, Z.-Y. Li, X. Sun and K. Yang, *Chin. Chem. Lett.*, 2022, **33**, 4269–4272.
- L. Tang, F. Yang, H. Cheng, C. Tan, C. Jin, H. Chen, Y. Huang, S. Zhang, W. Song and J. Tan, *Org. Lett.*, 2020, **22**, 8618–8623.
- Y. Lv, K. Sun, W. Pu, S. Mao, G. Li, J. Niu, Q. Chen and T. Wang, *RSC Adv.*, 2016, **6**, 93486–93490.
- B. He, Z. Xiao, H. Wu, Y. Guo, Q.-Y. Chen and C. Liu, *RSC Adv.*, 2017, **7**, 880–883.
- X. Yi, S. Lei, W. Liu, F. Che, C. Yu, X. Liu, Z. Wang, X. Zhou and Y. Zhang, *Org. Lett.*, 2020, **22**, 4583–4587.
- J. A. Buss, A. Vasilopoulos, D. L. Golden and S. S. Stahl, *Org. Lett.*, 2020, **22**, 5749–5752.
- S. Sushmita, T. Aggarwal, N. Shibata and A. K. Verma, *Chem.–Eur. J.*, 2019, **25**, 16063–16067.
- S. Han, X. Gao, Q. Wu, J. Li, D. Zou, Y. Wu and Y. Wu, *Org. Chem. Front.*, 2019, **6**, 830–834.
- R.-J. Tang, C.-P. Luo, L. Yang and C.-J. Li, *Adv. Synth. Catal.*, 2013, **355**, 869–873.
- K. Kaneko, T. Yoshino, S. Matsunaga and M. Kanai, *Org. Lett.*, 2013, **15**, 2502–2505.
- P. A. Sibbald and F. E. Michael, *Org. Lett.*, 2009, **11**, 1147–1149.
- B. E. Haines, T. Kawakami, K. Kuwata, K. Murakami, K. Itami and D. G. Musaev, *Chem. Sci.*, 2017, **8**, 988–1001.
- W. Wang, L. Zhao, H. Wu, Y. He and G. Wu, *Org. Lett.*, 2023, **25**, 7078–7082.
- K. Zhou, L. Yin, Y. Guo, C.-H. Ding and B. Xu, *Synthesis*, 2022, **55**, 744–754.
- A. Zhou, Y. Shao, F. Chen, P.-C. Qian and J. Cheng, *Tetrahedron Lett.*, 2022, **89**, 153597.
- S. Yang, C. Liu, X. Shangguan, Y. Li and Q. Zhang, *Chem. Sci.*, 2022, **13**, 13117–13121.





- 42 D. Hao, Z. Yang, Y. Liu, Y. Li, Y. Liu and P. Liu, *J. Mol. Struct.*, 2022, **1267**, 133636.
- 43 S.-C. Wang, M.-N. Feng, Y. Ji, W.-W. Han, C.-Y. Ke, Q.-Z. Zhang and X.-L. Zhang, *RSC Adv.*, 2021, **11**, 12136–12140.
- 44 Z. Shao, F. Wang, J. Shi, L. Ma and Z. Li, *Org. Chem. Front.*, 2021, **8**, 3298–3307.
- 45 T. W. Pouambeka, G. C. Enoua, F. C. Bopoundza, H. Makomo, B. W. Loumouamou and Q. Zhan, *Adv. J. Chem., Sect. B*, 2021, **3**, 176–187.
- 46 Z. Li, L. Ye, Y. Cao, J. Qin, W. Wang and Y. Xie, *Tetrahedron Lett.*, 2021, **83**, 153427.
- 47 B. Lei, Q. Miao, L. Ma, R. Fu, F. Hu, N. Ni and Z. Li, *Org. Biomol. Chem.*, 2019, **17**, 2126–2133.
- 48 W.-B. Cao, X.-P. Xu and S.-J. Ji, *Adv. Synth. Catal.*, 2019, **361**, 1771–1776.
- 49 F. Bao, Y. Cao, W. Liu and J. Zhu, *RSC Adv.*, 2019, **9**, 27892–27895.
- 50 Y.-c. Wang, L.-q. Liu, G.-m. Wang, H. Ouyang and Y.-j. Li, *Green Chem.*, 2018, **20**, 604–608.
- 51 S. Samanta and A. Hajra, *J. Org. Chem.*, 2018, **83**, 13157–13165.
- 52 C. R. Reddy, S. K. Prajapati and R. Ranjan, *Org. Lett.*, 2018, **20**, 3128–3131.
- 53 W. Yuan and K. J. Szabó, *ACS Catal.*, 2016, **6**, 6687–6691.
- 54 D. Yang, M. Sun, W. Wei, J. Li, P. Sun, Q. Zhang, L. Tian and H. Wang, *RSC Adv.*, 2016, **6**, 72361–72365.
- 55 X.-F. Xia, S.-L. Zhu, J.-B. Liu, D. Wang and Y.-M. Liang, *J. Org. Chem.*, 2016, **81**, 12482–12488.
- 56 C. Herrera-Leyton, M. Madrid-Rojas, J. J. López, Á. Cañete, P. Hermosilla-Ibáñez and E. G. Pérez, *ChemCatChem*, 2016, **8**, 2015–2018.
- 57 Z. Ni, Q. Zhang, T. Xiong, Y. Zheng, Y. Li, H. Zhang, J. Zhang and Q. Liu, *Angew. Chem., Int. Ed.*, 2012, **51**, 1244–1247.
- 58 T. Xiong, Y. Li, Y. Lv and Q. Zhang, *Chem. Commun.*, 2010, **46**, 6831–6833.
- 59 P. A. Sibbald, C. F. Rosewall, R. D. Swartz and F. E. Michael, *J. Am. Chem. Soc.*, 2009, **131**, 15945–15951.
- 60 Y. Yin, J. Xie, F.-Q. Huang, L.-W. Qi and B. Zhang, *Adv. Synth. Catal.*, 2017, **359**, 1037–1042.
- 61 S. Lu, L.-L. Tian, T.-W. Cui, Y.-S. Zhu, X. Zhu, X.-Q. Hao and M.-P. Song, *J. Org. Chem.*, 2018, **83**, 13991–14000.
- 62 X. Wang, B. Lei, L. Ma, H. Jiao, W. Xing, J. Chen and Z. Li, *Adv. Synth. Catal.*, 2017, **359**, 4284–4288.
- 63 S. Wang, Z. Ni, X. Huang, J. Wang and Y. Pan, *Org. Lett.*, 2014, **16**, 5648–5651.
- 64 K. Sun, Y. Li, T. Xiong, J. Zhang and Q. Zhang, *J. Am. Chem. Soc.*, 2011, **133**, 1694–1697.
- 65 W.-M. Gao, L. Hu, F. Gao, G. Hu and X. Zhou, *J. Chem. Res.*, 2024, **48**, 17475198231226425.
- 66 X. Jia, X. Tian, D. Zhuang, Z. Wan, J. Gu and Z. Li, *Org. Lett.*, 2023, **25**, 2012–2017.
- 67 G. B. Boursalian, M.-Y. Ngai, K. N. Hojczyk and T. Ritter, *J. Am. Chem. Soc.*, 2013, **135**, 13278–13281.
- 68 M. Singsardar, S. Mondal, R. Sarkar and A. Hajra, *ACS Omega*, 2018, **3**, 12505–12512.
- 69 Y. Wang, Y. Wang, Z. Guo, Q. Zhang and D. Li, *Asian J. Org. Chem.*, 2016, **5**, 1438–1441.
- 70 H.-H. Liu, Y. Wang, G. Deng and L. Yang, *Adv. Synth. Catal.*, 2013, **355**, 3369–3374.
- 71 D. Xiang, L. Xia, Y. Zhang, Q. Zhang and D. Li, *Synlett*, 2018, **29**, 1400–1404.
- 72 Y. Li, N. Lou and L. Gan, *Org. Lett.*, 2015, **17**, 524–527.
- 73 R. Van Lommel, P. Geerlings, T. Stuyver, S. L. C. Moors and F. De Proft, in *Chemical Reactivity*, ed. S. Kaya, L. von Szentpály, G. Serdaroğlu and L. Guo, Elsevier, 2023, pp. 243–275.
- 74 N. Stamenković, N. P. Ulrih and J. Cerkovnik, *Phys. Chem. Chem. Phys.*, 2021, **23**, 5051–5068.
- 75 M. Mandal, J. A. Buss, S.-J. Chen, C. J. Cramer and S. S. Stahl, *Chem. Sci.*, 2024, **15**, 1364–1373.
- 76 Y. Yang, Y. Yu, Y. Wang, Q. Zhang and D. Li, *Tetrahedron*, 2018, **74**, 1085–1091.
- 77 T. Qin, G. Lv, Q. Meng, G. Zhang, T. Xiong and Q. Zhang, *Angew. Chem., Int. Ed.*, 2021, **60**, 25949–25957.
- 78 L. He, Y. Zhu and Y. Xu, *ChemistrySelect*, 2021, **6**, 13559–13563.
- 79 P. Ghosh and A. Hajra, *J. Org. Chem.*, 2021, **86**, 10883–10888.
- 80 M. Iwasaki, K. Nonaka, S. Zou, Y. Sawanaka, T. Shinozaki, T. Fujii, K. Nakajima and Y. Nishihara, *J. Org. Chem.*, 2019, **84**, 15373–15379.
- 81 C. Li, S. Fan, Z. Wang and Z. Song, *Asian J. Org. Chem.*, 2024, **13**, e202300506.
- 82 Q. Miao, Z. Shao, C. Shi, L. Ma, F. Wang, R. Fu, H. Gao and Z. Li, *Chem. Commun.*, 2019, **55**, 7331–7334.
- 83 T. Stuyver, D. Danovich, F. De Proft and S. Shaik, *J. Am. Chem. Soc.*, 2019, **141**, 9719–9730.
- 84 G. W. T. M. J. Frisch, H. B. Schlegel, G. E. Scuseria, M. A. Robb, J. R. Cheeseman, G. Scalmani, V. Barone, B. Mennucci, G. A. Petersson, H. Nakatsuji, M. Caricato, X. Li, H. P. Hratchian, A. F. Izmaylov, J. Bloino, G. Zheng, J. L. Sonnenberg, M. Hada, M. Ehara, K. Toyota, R. Fukuda, J. Hasegawa, M. Ishida, T. Nakajima, Y. Honda, O. Kitao, H. Nakai, T. Vreven, J. A. Montgomery Jr, J. E. Peralta, F. Ogliaro, M. Bearpark, J. J. Heyd, E. Brothers, K. N. Kudin, V. N. Staroverov, T. Keith, R. Kobayashi, J. Normand, K. Raghavachari, A. Rendell, J. C. Burant, S. S. Iyengar, J. Tomasi, M. Cossi, N. Rega, J. M. Millam, M. Klene, J. E. Knox, J. B. Cross, V. Bakken, C. Adamo, J. Jaramillo, R. Gomperts, R. E. Stratmann, O. Yazyev, A. J. Austin, R. Cammi, C. Pomelli, J. W. Ochterski, R. L. Martin, K. Morokuma, V. G. Zakrzewski, G. A. Voth, P. Salvador, J. J. Dannenberg, S. Dapprich, A. D. Daniels, O. Farkas, J. B. Foresman, J. V. Ortiz, J. Cioslowski and D. J. Fox, *Gaussian 09*, Gaussian, Inc., Wallingford, CT, 2013.
- 85 B. Galabov, D. Nalbantova, P. v. R. Schleyer and H. F. Schaefer III, *Acc. Chem. Res.*, 2016, **49**, 1191–1199.

